Technological aspects of preparation CdTe (CdZnTe) MESA pixel detectors

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Introduction

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Study of Au/p-CdTe contacts, influence of temperature gradient

Introduction

perspective. electrodes as well, the above mention application is becoming very improvements in the technology of crystals production and in the design of Si $(Z_{Cd} = 48, Z_{Te} = 52)$ and large band gap $(E_g = 1, 5 \text{ eV})$ which allows in contrast to Si detector operate at room temperature. Due to recent [1] [2] such application, namely high quantum efficiency in comparison e.g. With physics but also in astrophysics. There are at least two good reasons for detectors for X-ray and gamma rays spectroscopy not only in high-energy been regarded as a very promising material for the exploitation in imaging Cadmium telluride (CdTe) and cadmium zinc telluride (CdZnTe) have

The preparation of MESA pixel detector

the literature in detail, almost comprises planar pixel or strip detector. As known in MESA pixel detectors the interface metal - semiconductor appearing on The preparation of MESA pixel detector is not for the time being described in

surface (Br/ methanol) is covered by Au contact (electroless deposition) and suitable surface masking. Nevertheless we find this technique prospective for started with plasmatic etching of CdTe but in this case we faced the problem of small pixels (1 x 1 mm) in (110) crystalografic direction. At first we have than is certain cases few pixels were engraved on it or sample was pinched on Our experiment is based (see Fig.1) on the procedure during which etched MESA pixel preparation and so we proceed the measurements. surface can be better protected.

The polarization effect

detectors polarize in time and sample detectivity changes. It should be mention phonon drag effect the dominant role play optical phonons. that CdTe has 72 percents ionic bond and therefore in scattering effects and in by lattice defects but due to the applied external electric field (100 -400 V) the chlorine). It is true that during the doping procedure self compensation appears reduction is possible only during the preparation of starting bulk material of literature described, explained and experimentally verified. It is evident that its CdTe by suitable temperations (e. g. high resistance samples doped by The polarization effect (amplitude degradation of spectra in time)

Study of Au/p-CdTe contacts, influence of temperature gradient

characteristics. Summarizing these measurements we have concluded that the Many our papers [2-11] Schottky contact must be described by modified Bethe theory [3]. were devoted to the measurements of I-V

have measured simultaneously on these structures Seebeck effect and plausible temperature gradient on Au/p-CdTe/Au which were published in [5-11]. We equilibrium carriers in bipolar semiconductors explanation was found by means of Gurevich theory [4] about the role of non-Interesting results were obtained on the shift of I-V characteristics with

In connection with these measurements probably a question arises - why are

we speaking about temperature gradient?

It is known, that thermal conductivity CdTe is 7,5 Wm⁻¹K⁻¹ and Si is 145

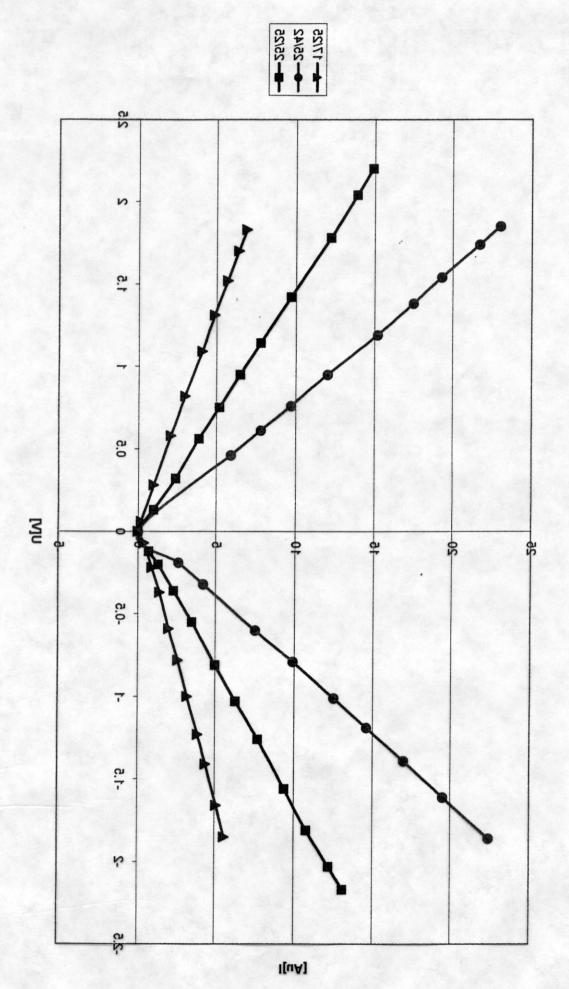
W m-1K-1.

up by electronic circuits which produce a certain amount of heat. can appear quite independently on our expectation. The detector can be warmed-Our detectors thickness is about 3-4 mm. In our detectors temperature gradient

resistivity increase (see Tab. 1) multiple resistivity increase, on the contrary its warming of about 7 C produced difference (17, 25 °C) due to cooling of one end of about 8 C produced five arisen temperature gradient using device simulator. While temperature temperature gradient, while Fig. 2 shows the shift of I -V characteristics due to Fig. 1 shows the shift of our measured I -V characteristics due to arisen

Tab.1

2542	2517	2525	Temperature °C
1,12	6,5	1,5	R.10 ⁻⁵ ohm) polarity
1,38	8,1	1,68	ohm)
	1		



iv char

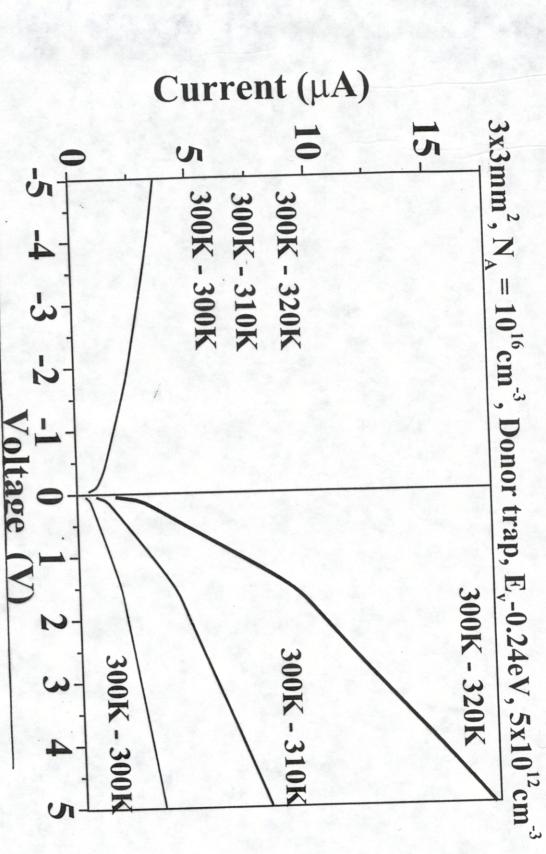


Fig. 2. Simulated dependences of I-U charactristics of the system Au/p-CdTe/Au for different (Simulator BLAZE from SILVACO Int. - prof. Ing. temperature differences J. Vobecký, DrSc., FEL CVUT in Prague)

the sample naturally changes in accordance with the relation of the whole sample and all changes appear in bulk resistance only. Volume resistance of change, than the other contact is direct bias that means it does not contribute to the resistance So long as one contact is maintained on constant temperature, its resistance alone does not

$$\frac{R}{R_0} = 1 + \frac{\Delta E \, \Delta T}{2k \, T_0^2} \, ,$$

similar effects are not known in other semiconductors as e. g. GaAs. can increase or decrease. We have observed these changes also in CdZnTe, consequence of this the changes appear also in detector depletion layer which the charge redistribution appear in semiconductor bulk which does not represent homogenous distribution but charge accumulation at one of the contacts. In mentioned relation, they are greater or lesser. In agreement with the theory [4] changes showed that the found values do not correspond exactly to the just difference, To represents the middle temperature of the sample. The temperature where Δ E is activation energy of bulk semiconductor, Δ T is temperature change of contact resistance must be also added. The analysis of our measured

Conclusion

- 1) We have succeeded in the preparation of the first MESA pixel prototypes
- 2) New results have brought the observation of temperature gradient produced on the detector.

Acknowledgement

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University, Ukraine). monocrystals of p-type CdTe (produced in Chernivtsy National For our investigation we have used as a bulk material

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